

NOTE: The course is delivered through face-to-face instruction, with the integration of independent preparation and group assignment/design studio days. Elements of the syllabus and course schedule are subject to adjustment based on those made by the Institute due to COVID-19 or any other extenuating circumstances. **Regular attendance and participation are expected, especially on design studio days, as peer critique and collaboration are integral to the learning process.**

significant distraction.

see, hear, speak, share work, and participate without

engage, question, try, document, test, listen,
reconsider, and revise.

You may not, without my written
consent, audio or video record my lectures.

not expected to hide unsuccessful attempts.

without typos

analysis, creative judgment, or authorship.

not replace your own thinking,

your process.

AI may participate in your process. It should not erase

<http://communicationcenter.gatech.edu/content/make-appointment> (Links to an external site.)Links to an external site.

<http://www.catalog.gatech.edu/policies/honor-code>
[/ http://www.catalog.gatech.edu/rules/18/](http://www.catalog.gatech.edu/rules/18/)

<http://www.catalog.gatech.edu/rules/4/>

[IAA form](#)

<http://disabilityservices.gatech.edu/>

<http://www.catalog.gatech.edu/rules/22/>

<http://www.catalog.gatech.edu/policies/honor-code>
[/ http://www.catalog.gatech.edu/rules/18/](http://www.catalog.gatech.edu/rules/18/)

<http://www.catalog.gatech.edu/rules/4/>

[IAA form](#)

<http://disabilityservices.gatech.edu/>

<http://www.catalog.gatech.edu/rules/22/>

green

red

purple